IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:	Group Art Unit: 1792
Yonhua Tzeng	Examiner: Stouffer, Kelly M.
Serial No.: 10/772,740	AMENDMENT AND RESPONSE TO
Filed: February 5, 2004	OFFICE ACTION MAILED May 12, 2008
For: METHOD OF PLASMA () ENHANCED CHEMICAL VAPOR () DEPOSITION OF DIAMOND () USING METHANOL-BASED ()	162 North Wolfe Road Sunnyvale, California 94086
SOLUTIONS)	(408) 530-9700
	Customer No.: 28960

Mail Stop AF Commissioner for Patents P.O. Box 1450 Alexandria, Virginia 22313-1450

AMENDMENTS

Sir:

Please amend the subject application as follows:

Amendments to the Claims are reflected in the listing of claims, which begins on page 2 of this paper.

Remarks/Arguments begin on page 7 of this paper.